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Box Patent Application

Assistant Commissioner of Patents and Trademarks Washington, D.C. 20231

Re:

Inventor(s):

IAN LATCHFORD; CHRISTOPHER DENNIS BENCHER; YUXIANG WANG

and MARIO DAVE SILVETTI

Title:

PHOTOLITHOGRAPHY SCHEME USING A SILICON CONTAINING

RESIST

Transn	nitted herewith is the patent application identified above, including:	0 E			
<u>x</u>	Specification, claims and abstract, totaling 32 pages.	219.			
<u>x</u>	Drawings totaling 12 pages, X Formal Informal.	20 20 20 20 20 20 20 20 20 20 20 20 20 2			
<u>x</u>	Executed Declaration and Power of Attorney.	, H			
<u>X</u>	Information Disclosure Statement w/ Form 1449 and References.				
X	Assignment of the invention to Applied Materials, Inc.				

Assignment Recordation Cover Sheet X

FEE CALC	CULATIO	NC:					
Fee Items	Claims Filed	Included With Basic Fee	Extra Claims	Fee Rate	Total		
Total Claims	44	-20=	24	x \$18.00	\$432.00		
Independent Claims	3	-3=	. 0	x \$80.00	0		
Basic Filing Fee	\$710.00						
TOTAL FEES	\$1142.00						

The Commissioner is hereby authorized to charge \$1142.00 to Deposit Account No. Х 50-1074/4375/DD/BCVD/.

- The Commissioner is hereby authorized to charge any additional fees which may be required, X or credit any overpayment to Deposit Account No. 50-1074/4375/DD/BCVD/. A duplicate copy of this transmittal is enclosed.
- X Please address all future correspondence to:

PATENT COUNSEL APPLIED MATERIALS, INC.

Legal Affairs Department

P.O.BOX 450A

Santa Clara, CA. 95052

I hereby certify that this correspondence is being deposited with the United States Postal Service as express mail in an envelope addressed to: Commissioner of Patents and Trademarks, Washington, D.C. 20231.

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Respectfully submitted

Robert W. Mulcahy Registration No. 25,436

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